

|    | Hits | Search Text   | DBs   |
|----|------|---|---|
| 41 | 8    | ((coat\$4 or film or form\$4 or layer ) same (photoresist or resist or polymide) same (substrate or wafer or device) same (microlens or non\$4planar or circuit\$4) same spray\$4 same angle)   | US-PGPUB;<br>USPAT; FPRS;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB |
| 42 | 2    | ((coat\$4 or film or form\$4 or layer ) same (photoresist or resist or polymide) same (substrate or wafer or device) same (microlens or non\$4planar or circuit\$4)) and ((photoresist or polyimide or photosensitive or resist) near16 spray\$4 near6 (coat\$4 or apply or application or form\$3 or deposit\$4 or layer or dispens\$4) near16 angle)    | US-PGPUB;<br>USPAT; FPRS;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB |
| 43 | 3    | ((coat\$4 or film or form\$4 or layer ) same (photoresist or resist or polymide) same (substrate or wafer or device) same (microlens or non\$4planar or circuit\$4)) and ((photoresist or polyimide or photosensitive or resist) near16 spray\$4 near6 (coat\$4 or apply\$3 or application or form\$3 or deposit\$4 or layer or dispens\$4) near16 angle) | US-PGPUB;<br>USPAT; FPRS;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB |
| 44 | 9    | ((coat\$4 or film or form\$4 or layer ) same (photoresist or resist or polymide) same (substrate or wafer or device) same (microlens or non\$4planar or circuit\$4)) and ((photoresist or polyimide or photosensitive or resist) near16 spray\$4 near16 angle)  | US-PGPUB;<br>USPAT; FPRS;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB |